

BEST AVAILABLE COPY

RECEIVED
CENTRAL FAX CENTER
FEB 09 2007

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061,477
Customer No. 42717

REMARKS

Claims 28-48 are pending in the application. In view of the remarks that follow, Applicants respectfully request reconsideration.

Allowable Subject Matter

Noted with appreciation is the indication in the Office Action that Claims 29-30, 32, 34-36, 38-39 and 42-48 are all considered to be allowable.

Objection to Incomplete Office Action

Applicants respectfully object to the present Office Action, on the ground that it is not complete. More specifically, the most recent prior Office Action was mailed on July 17, 2006. That prior Office Action rejected several claims under 35 U.S.C. §103 for obviousness. On August 29, 2006, Applicants filed a Response to the July 17 Office Action. The Response presented arguments against the §103 rejections. In due course, the Examiner issued the present Office Action on November 17, 2006. The present Office Action repeats the prior §103 rejection verbatim, with no changes. The provisions of MPEP §707.07(f) instruct examiners that:

Where the applicant traverses any rejection, the examiner should, if he or she repeats the rejection, take note of the applicant's argument and answer the substance of it.

However, the present Office Action fails to meet this PTO requirement. In particular, the present Office Action does not contain a single word of reply to the arguments presented in Applicants' last Response. In fact, Applicants' last Response presented several separate and distinct grounds of argument, and the present Office Action fails to recognize and answer any of these different arguments, much less recognize and answer all of them, as required by MPEP 707.07(f).

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

Summarizing, the present Office Action repeats a §103 rejection from the last Office Action, but fails to "take note of the applicant's argument and answer the substance of it". Accordingly, it is respectfully submitted that the present Office Action is not complete, because it fails to comply with the PTO requirement set forth in MPEP §707.07(f). Consequently, the present Office Action must be withdrawn, and replaced with a new and complete Office Action that does comply with MPEP 707.07(f).

Since the present Office Action is clearly incomplete and will have to be withdrawn, Applicants have no obligation to address the §103 rejection on the merits (because Applicants have already addressed it on the merits and the Examiner has not yet considered and replied to Applicants' arguments). Nevertheless, as a courtesy, Applicants present below the very same arguments that were presented in Applicants last Response, because the Examiner still needs to consider and respond to these arguments.

Independent Claim 28

Independent Claim 28 stands rejected under 35 U.S.C. §103 as obvious in view of a proposed combination of teachings from Yu U.S. Patent No. 6,784,101 and Rim U.S. Patent No. 6,603,156. This rejection is respectfully traversed. The PTO specifies in MPEP §2142 that:

The examiner bears the initial burden of factually supporting any *prima facie* conclusion of obviousness. If the examiner does not produce a *prima facie* case, the applicant is under no obligation to submit evidence of nonobviousness.

Applicants respectfully submit that Yu and Rim fail to establish a *prima facie* case of obviousness under §103 with respect to Claim 28, for several mutually exclusive reasons that are discussed separately below.

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

YU AND RIM FAIL TO TEACH ALL OF THE CLAIM LIMITATIONS

The provisions of MPEP §2142 specify with respect to §103 that:

To establish a *prima facie* case of obviousness . . . the prior art reference (or references when combined) must teach or suggest all the claim limitations. (Emphasis added).

The PTO considers this requirement to be important, as evidenced by the fact that this exact language appears not only in MPEP §2142, but also in other sections of the MPEP, including MPEP §706.02(j) and MPEP §2143. Applicants' Claim 28 includes a recitation of:

... a strained substrate . . . comprising an uppermost strained-Si epi layer, a middle relaxed Si_{1-x}Ge_x layer and a lowermost graded Si_{1-y} Ge_y layer;

at least one dielectric gate oxide portion over the strained substrate, the at least one dielectric gate oxide portion having a dielectric constant of greater than about 4.0; and

a device over each of the at least one dielectric gate oxide portion to complete the at least one high-k device.

The Office Action relies on Figure 7 of Yu, which discloses a relaxed SiGe layer 3, a high-k dielectric layer 6', and a device gate electrode 8. However, Figure 7 of Yu does not disclose a strained epi-Si layer or a second graded SiGe layer. In an attempt to cure these deficiencies in Yu, the Office Action turns to Rim, and in particular to Figure 1 of Rim. Figure 1 of Rim depicts a process flow that progresses from left to right, and that shows several different ways to

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

fabricate a structure 10 shown at the right side of Figure 1. The structure 10 has a strained epi-Si layer 12, an insulator layer 14, and a layer 24 that serves as a "handle". However, the final structure 10 of Figure 1 does not include a graded SiGe layer. Consequently, even when Figure 7 of Yu and Figure 1 of Rim are considered together, they show only one graded SiGe layer (at 3 in Figure 7 of Yu). Since they do not show two different SiGe layers, they fail to satisfy the requirement of MPEP §2142 that their combined teachings must "teach or suggest all the claim limitations" (emphasis added). Therefore, for this independent reason alone, it is respectfully submitted that Claim 28 is not rendered obvious under §103 by Yu and Rim, and notice to that effect is respectfully requested.

PTO MUST CONSIDER INVENTION AS A WHOLE, NOT JUST A DIFFERENCE

In the present Office Action, the Examiner indicates that Yu discloses a device with a strained layer, but acknowledges that there are differences between Yu and the subject matter of Claim 28. For example, the Examiner admits that "Yu et al. fail to disclose the required epi-silicon structure". The Examiner then focuses on this difference, and goes off to look for a reference that discloses this difference.

More specifically, the Examiner notes that Figure 1 of Rim discloses a strained epi-Si layer at 12. As noted above, Rim's Figure 1 shows a process flow from left to right, and the relevant part of Figure 1 is the final structure 10 shown on the right. This structure 10 has a strained epi-Si layer 12, an insulator layer 14, and a layer 24 that serves as a "handle". Aside from the presence of the strained epi-Si layer 12, the structure 10 bears little or no resemblance to anything disclosed in Yu or anything recited in Claim 28. In regard to the subject matter of Claim 28, Rim basically discloses just a strained epi-Si layer, and nothing else of interest.

Thus, the Office Action identifies a difference between Yu and Claim 28 (a strained epi-Si layer), and then focuses solely on this difference, without regard to context. In effect, the Examiner assumes that if a strained epi-Si layer can itself be shown to be obvious, then

AppL No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

Applicants' overall invention must also necessarily be obvious. But this approach is expressly prohibited by MPEP §2141.02, which emphasizes that:

**THE CLAIMED INVENTION MUST BE CONSIDERED
AS A WHOLE**

In determining the differences between the prior art and the claims, the question under 35 U.S.C. §103 is not whether the differences themselves would have been obvious, but whether the claimed invention as a whole would have been obvious. (Emphasis in original).

Applicants respectfully submit that the approach taken in the Office Action runs afoul of this MPEP requirement. Accordingly, for this independent reason alone, it is respectfully submitted that, when considered as a whole, Claim 28 is not rendered obvious under §103 by Yu and Rim.

THERE IS NO MOTIVATION TO MAKE THE PROPOSED COMBINATION

MPEP §2142 specifies that:

To establish a *prima facie* case of obviousness . . . there must be some suggestion or motivation, either in the references themselves or in the knowledge generally available to one of ordinary skill in the art, to modify the reference or to combine reference teachings. . . . The teaching or suggestion to make the claimed combination . . . must . . . be found in the prior art, and not based on applicant's disclosure.

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

In the present Office Action, the Examiner asserts that:

It would have been obvious to one of . . . ordinary skill in the art at the time the invention was made to include the required epi-silicon layer . . . in Yu et al. as taught by Rim in order to have a semiconductor device with increased reliability and performance.

There are at least two problems with this statement. First, as discussed above, Yu not only lacks a strained epi-Si layer, but also has only one SiGe layer, whereas Claim 28 recites two different SiGe layers. The statement quoted from the Office Action about motivation says absolutely nothing about motivation in regard to the second SiGe layer. In particular, the Office Action does not identify any prior art that teaches the use of two different SiGe layers, and the quoted statement about motivation offers no explanation about why a person skilled in the art would be motivated to modify Yu to provide two different SiGe layers, especially since the rejection is based on prior art that does not disclose the use of two different SiGe layers.

Second, in regard to the strained epi-Si layer, the quoted statement regarding motivation asserts that it would be obvious to modify Yu to replace the semiconductor layer 2 with the strained epi-Si layer 12 of Rim "in order to have a device with increased reliability and performance". This statement about "increased reliability and performance" is a conclusory assertion that is not supported by the citation of any specific statement in Rim about either reliability or performance. And even assuming Rim indicated that his strained epi-Si layer 12 served to enhance either reliability or performance of the structure shown at 10 in Figure 1 of Rim, Rim's structure 10 is so radically different from the structure shown in Figure 7 of Yu that there is no reason to believe the strained epi-Si layer 12 of Rim would serve to increase either reliability or performance in the radically different device of Yu. Consequently, as to the strained epi-Si layer, the Office Action does not show any proper motivation for making the proposed combination.

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

MPEP §2142 provides that:

To reach a proper determination under §103, the examiner must step backward in time and into the shoes worn by the hypothetical "person of ordinary skill in the art" when the invention was unknown and just before it was made. . . . Knowledge of applicant's disclosure must be put aside in reaching this determination, . . . impermissible hindsight must be avoided, and the legal conclusion must be reached on the basis of the facts gleaned from the prior art.

In the present Office Action , the rejection of Claim 28 based on Yu and Rim is actually nothing more than a hindsight reconstruction of Applicants' device. Using Applicants' disclosure as a blueprint, the Examiner selectively extracted isolated structural features from both Yu and Rim, and then combined these isolated features with a 20/20 view of the desired result. As part of this, the idea of using two different SiGe layers was clearly pulled from Applicants' disclosure and not the prior art, because it is certainly not taught in the indicated portions of either Yu or Rim. This is a classic example of hindsight reconstruction. Examiners frequently attempt to justify the use of hindsight by turning to PTO Form Paragraph 7.37.03, which states that "any judgment on obviousness is in a sense necessarily a reconstruction based upon hindsight reasoning". However, even this form paragraph goes on to emphasize that hindsight is permissible only to the extent that it "does not include knowledge gleaned only from the applicant's disclosure" (emphasis added). Here, Yu and Rim cannot possibly render the subject matter of Claim 28 obvious, unless the analysis also includes hindsight of Applicant's disclosure. But MPEP §2142 and Form Paragraph 7.37.03 both make it very clear that hindsight of Applicant's disclosure cannot be used under §103. Accordingly, for this independent reason alone, it is respectfully

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

submitted that Claim 28 is not rendered obvious under §103 by Yu and Rim, and notice to that effect is respectfully requested.

For each of the various different reasons discussed above, it is respectfully submitted that the Office Action fails to establish a prima facie case of obviousness with respect to Claim 28. Accordingly, Claim 28 is not rendered obvious under §103 by Yu and Rim. Claim 28 is therefore believed to be allowable, and notice to that effect is respectfully requested.

Independent Claims 33 and 41

As noted above, independent Claims 33 and 41 were each previously allowed, but the Examiner has now withdrawn that allowance in order to set forth a rejection of Claims 33 and 41. In particular, Claims 33 and 41 each stand rejected under 35 U.S.C. §103 as obvious in view of Yu and Rim. These rejections are respectfully traversed. Claim 33 includes a recitation of:

... a strained substrate . . . comprising an uppermost strained-Si epi layer over an upper relaxed Si_{1-x}Ge_x layer over a graded Si_{1-y} Ge_y layer over an epi layer over a lowermost relaxed Si_{1-z} Ge_z layer, wherein x≥y≥z; . . .

Claim 41 includes a recitation of:

... a strained substrate . . . comprising an uppermost strained-Si epi layer, a relaxed Si_{1-y} Ge_y layer under the uppermost strained-Si epi layer, a constant Si_{1-y} Ge_y layer under the relaxed Si_{1-y} Ge_y layer, a silicon epi layer under the constant Si_{1-y} Ge_y layer, and a constant Si_{1-z} Ge_z layer under the silicon epi layer, wherein the uppermost relaxed-Si epi layer is comprised of Si_{1-x} Ge_x wherein x is constant or graded; . . .

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

The rationale given in the Office Action for the rejection of Claims 33 and 41 is the same rationale given for the rejection of Claim 28. Claims 33 and 41 each recite a strained epi-Si layer and, for the same basic reasons discussed above in association with Claim 28, it is respectfully submitted that it would not be obvious in view of Figure 1 of Rim to provide a strained epi-Si layer in the device shown in Figure 7 of Yu. In addition, Claims 33 and 41 each recite an arrangement that has three different SiGe layers with an embedded epi layer. The idea for this arrangement is clearly being pulled from Applicants' disclosure through the improper use of hindsight, because it is certainly not taught in the indicated portions of either Yu or Rim.

Accordingly, it is respectfully submitted that the Office Action fails to establish a prima facie case of obviousness for either of Claims 33 and 41 based on Yu and Rim. Claims 33 and 41 are therefore believed to be allowable, and notice to that effect is respectfully requested.

Independent Claim 31

As noted above, independent Claim 31 was previously allowed, but the Examiner has now withdrawn that allowance in order to set forth a rejection of Claim 31. In particular, Claim 31 stands rejected under 35 U.S.C. §103 as obvious in view of Yu and Rim. This rejection is respectfully traversed. Claim 31 includes a recitation of:

... a strained substrate . . . comprising an uppermost strained-Si epi layer, a middle $\text{Si}_{1-x}\text{Ge}_x$ layer and a lower silicon oxide layer; . . .

The rationale given in the Office Action for the rejection of Claim 31 is the same rationale given for the rejection of Claim 28. Claim 31 recites a strained epi-Si layer and, for the same basic reasons discussed above in association with Claim 28, it is respectfully submitted that it would not be obvious in view of Figure 1 of Rim to provide a strained epi-Si layer in the device shown

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

in Figure 7 of Yu. It is respectfully submitted that the idea for this proposed modification is clearly being pulled from Applicants' disclosure through the improper use of hindsight. Accordingly, it is respectfully submitted that the Office Action fails to establish a prima facie case of obviousness for Claim 31 based on Yu and Rim. Claim 31 is therefore believed to be allowable, and notice to that effect is respectfully requested.

Dependent Claim 37

Claim 37 depends from independent Claim 33, and is also believed to be distinct from the art of record, for example for the same reasons discussed above with respect to Claim 33.

Conclusion

Based on the foregoing, it is respectfully submitted that all of the pending claims are fully allowable, and favorable reconsideration of this application is therefore respectfully requested. If the Examiner believes that examination of the present application may be advanced in any way by a telephone conference, the Examiner is invited to telephone the undersigned attorney at 972-739-8647.

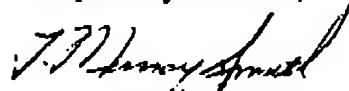
Although Applicants believe that no fee is due in association with the filing of this Response, the Commissioner is hereby authorized to charge any additional fee required by this

Appl. No. 10/762,164
Reply to Office Action of November 17, 2006

Attorney Docket No. 2002-0246 / 24061.477
Customer No. 42717

paper, or to credit any overpayment, to Deposit Account No. 08-1394 of Haynes and Boone LLP.

Respectfully submitted,



T. Murray Smith
Registration No. 30,222
(972) 739-8647

Date: February 9, 2007

HAYNES AND BOONE, LLP
901 Main Street, Suite 3100
Dallas, Texas 75202-3789
Telephone: (972) 739-8647
Facsimile: (214) 200-0853
File: 24061.477

Enclosure: None

R-154746.1

**This Page is Inserted by IFW Indexing and Scanning
Operations and is not part of the Official Record**

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images include but are not limited to the items checked:

- BLACK BORDERS**
- IMAGE CUT OFF AT TOP, BOTTOM OR SIDES**
- FADED TEXT OR DRAWING**
- BLURRED OR ILLEGIBLE TEXT OR DRAWING**
- SKEWED/SLANTED IMAGES**
- COLOR OR BLACK AND WHITE PHOTOGRAPHS**
- GRAY SCALE DOCUMENTS**
- LINES OR MARKS ON ORIGINAL DOCUMENT**
- REFERENCE(S) OR EXHIBIT(S) SUBMITTED ARE POOR QUALITY**
- OTHER:** _____

IMAGES ARE BEST AVAILABLE COPY.

As rescanning these documents will not correct the image problems checked, please do not report these problems to the IFW Image Problem Mailbox.